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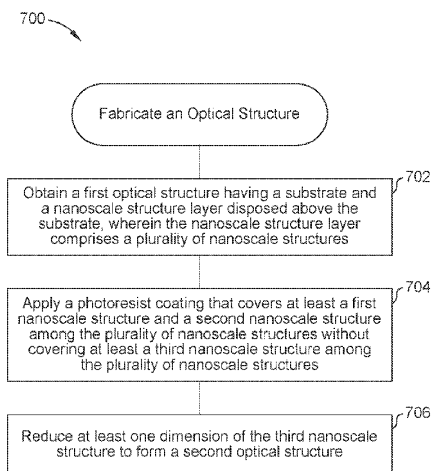


FIG. 7

(57) Abstract: Aspects of the present disclosure provide methods of fabricating an optical structure. An example method includes obtaining a first optical structure having a substrate and a nanoscale structure layer disposed above the substrate, wherein the nanoscale structure layer comprises a plurality of nanoscale structures. The method further includes applying a photoresist coating that covers at least a first nanoscale structure and a second nanoscale structure among the plurality of nanoscale structures without covering at least a third nanoscale structure among the plurality of nanoscale structures. The method further includes reducing at least one dimension of the third nanoscale structure to form a second optical structure.

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